

Electronic Supplementary Information

Highly Porous Carbon-Coated Silicon Nanoparticles with Canyon-Like Surfaces as a High-Performance Anode Material for Li-Ion Batteries

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Calculation 1: Ratio of total pore volume to Si volume

Ratio of total pore volume to Si volume was calculated assuming 1 g of Si.

Total pore volume / Volume of Si

$$= [\text{Total pore volume (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / \text{Specific volume of Si (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

$$= [\text{Total pore volume (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / 0.4294 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

Based on this equation, the ratio of total pore volume to Si volume can be calculated for each sample.

(1) For npSi

When the measured total pore volume (0.03 cm³ g_{Si}⁻¹) was utilized for the calculation,

$$[0.03 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / 0.4294 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

$$= \mathbf{6.99\%}$$

(2) For pSi

When the measured total pore volume (0.716 cm³ g_{Si}⁻¹) was utilized for the calculation,

$$[0.716 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / 0.4294 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

$$= \mathbf{167\%}$$

When the expected total pore volume (0.801 cm³ g_{Si}⁻¹) was utilized for the calculation (see Calculation 2 for the details of calculating expected total pore volume),

$$[0.801 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / 0.4294 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

$$= \mathbf{187\%}$$

(3) For cpSi

The total pore volume of cpSi was calculated by adding the pore volume from MgO etching and the pore volume of the canyon-like structure because direct measurement of the pSi structure cannot be implemented owing to the collapse of the canyon-like structure after MgO etching without carbon coating. The pore volume from MgO etching (0.801 cm³ g_{Si}⁻¹) from Calculation 2 was adopted, and the pore volume of the canyon-like structure (1.01 cm³ g_{Si}⁻¹) is adopted from Calculation 3. Therefore, the ratio of the pore volume to Si volume can be calculated as follows:

$$[1.802 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}} / 0.4294 \text{ (cm}^3 \text{ g}_{\text{Si}}^{-1}) \times 1 \text{ g}_{\text{Si}}] \times 100 (\%)$$

$$= \mathbf{419\%}$$

Calculation 2: Expected total pore volume of pSi

In this calculation, the total pore volume of pSi is assumed to be derived only from MgO etching. In our calculation, we assumed 1 mol of SiO₂ and 2 mol of Mg was used for magnesiothermic reduction (SiO₂(s) + 2Mg(g) → Si(s) + 2MgO(s)). When the reaction completes, a composite of 1 mol of Si and 2 mol of MgO is obtained. As the MgO volume would become the pore volume, we can calculate the total pore volume by the following equation:

$$\begin{aligned} & (\text{Volume of MgO}) / (\text{mass of Si}) \\ &= [(\text{mole of MgO}) \times (\text{molecular weight of MgO}) \div (\text{density of MgO})] / [(\text{mole of Si}) \times (\text{molecular weight of Si})] \\ &= (2 \text{ mol} \times 40.3044 \text{ g mol}^{-1} \div 3.58 \text{ g cm}^{-3}) / (1 \text{ mol} \times 28.0855 \text{ g mol}^{-1}) \\ &= \mathbf{0.801 \text{ cm}^3 \text{ g}_{\text{Si}}^{-1}}. \end{aligned}$$

Calculation 3: Pore volume of canyon-like structure

The pore volume of the canyon-like structure can be obtained from the pore volume of cpSi+MgO (0.26 cm³ g_{Si+MgO}⁻¹) as measured by N₂ sorption. Conversion of the unit into the pore volume per mass of Si was necessary, so the following calculation was conducted:

Assuming a complete magnesiothermic reduction with 1 mol of SiO₂ and 2 mol of Mg, we can obtain 1 mol of Si and 2 mol of MgO. As 1 mol of Si is 28.0855 g and 2 mol of MgO is 80.6088 g, the total mass of Si+MgO would be 108.6943 g. When the Si+MgO composite was converted to Si, the weight of MgO was lost. Therefore, the pore volume of the canyon-like structure in the final structure should be:

$$0.26 \text{ cm}^3 \text{ g}_{\text{Si+MgO}}^{-1} \times 108.6943 \text{ g}_{\text{Si+MgO}} \div 28.0855 \text{ g}_{\text{Si}} = \mathbf{1.01 \text{ cm}^3 \text{ g}_{\text{Si}}^{-1}}$$

Calculation 4: Calculation of carbon wt% per contour surface area of Si nanoparticles

In order to calculate the carbon wt% per surface area, we measured the BET surface area of cpSi+MgO, pSi+MgO, and npSi. The BET surface areas of cpSi+MgO and pSi+MgO were utilized for this calculation because the carbon coating was performed before MgO etching, so the carbon only coated the contour surface region of the nanoparticle and not the surface of pores made by MgO etching. However, as the BET surface areas of cpSi+MgO and pSi+MgO are given in units of m² g_{Si+MgO}⁻¹, they should be converted to m² g_{Si}⁻¹ for the calculation and comparison with npSi. A similar conversion process as that used for Calculation 3 was performed, so the contour surface area of the Si nanoparticle on which carbon was coated can be calculated likewise:

$$(\text{Contour surface area of Si (m}^2 \text{ g}_{\text{Si}}^{-1}\text{)}) = (\text{measured surface area of Si+MgO (m}^2 \text{ g}_{\text{Si+MgO}}^{-1}\text{)}) \times (108.6943 \text{ g}_{\text{Si+MgO}} \div 28.0855 \text{ g}_{\text{Si}})$$

The results of this calculation are listed in Table S1.

Subsequently, carbon per surface area can be calculated using the carbon weight ratio to Si (g_C/g_{Si}) obtained from the carbon wt% (g_C/g_{Si+C} × 100) obtained by the TGA analysis in Figure S8.

(Carbon amount per contour Si surface area, g_C m⁻²)

$$= (\text{carbon weight ratio to Si weight, g}_C/\text{g}_{\text{Si}}) / (\text{modified Si surface area, m}^2 \text{ g}_{\text{Si}}^{-1}).$$

By this equation, we can obtain the values as follows:

1) For cpSi@C:

$$\begin{aligned} & 20.2 \text{ wt}\% \text{C} \div 175.58 \text{ m}^2 \text{ g}_{\text{Si}}^{-1} \\ &= (20.2 \text{ g}_C/100 \text{ g}_{\text{Si+C}}) \div 175.58 \text{ m}^2 \text{ g}_{\text{Si}}^{-1} = (20.2 \text{ g}_C/79.8 \text{ g}_{\text{Si}}) \div 175.58 \text{ m}^2 \text{ g}_{\text{Si}}^{-1} \\ &= \mathbf{0.00144 \text{ g}_C \text{ m}^{-2}} \end{aligned}$$

$$2) \text{ For pSi@C: } 7.98 \text{ wt}\% \text{C} / 63.04 \text{ m}^2 \text{ g}_{\text{Si}}^{-1} = \mathbf{0.00137 \text{ g}_C \text{ m}^{-2}}$$

$$3) \text{ For npSi@C: } 1.52 \text{ wt}\% \text{C} / 13.22 \text{ m}^2 \text{ g}_{\text{Si}}^{-1} = \mathbf{0.00117 \text{ g}_C \text{ m}^{-2}}$$

From these calculations, all the samples have virtually the same values, i.e. 0.00144 g_C m⁻² for cpSi@C, 0.00137 g_C m⁻² for pSi@C, and 0.00117 g_C m⁻² for npSi@C. As the carbon weight per contour surface area is associated with the thickness of the carbon layer on the nanoparticle, it can be concluded that we prepared Si-based materials with different pore morphologies but similar carbon thicknesses.

Calculation 5: Pore volume of pSi irrelevant with the MgO etching

Pore volume of pSi which does not originate from MgO etching can be calculated from the pore volume of pSi+MgO similarly as Calculation 3.

$$0.03 \text{ cm}^3 \text{ g}_{\text{Si+MgO}}^{-1} \times 108.6943 \text{ g}_{\text{Si+MgO}} \div 28.0855 \text{ g}_{\text{Si}} = \mathbf{0.12 \text{ cm}^3 \text{ g}_{\text{Si}}^{-1}}$$

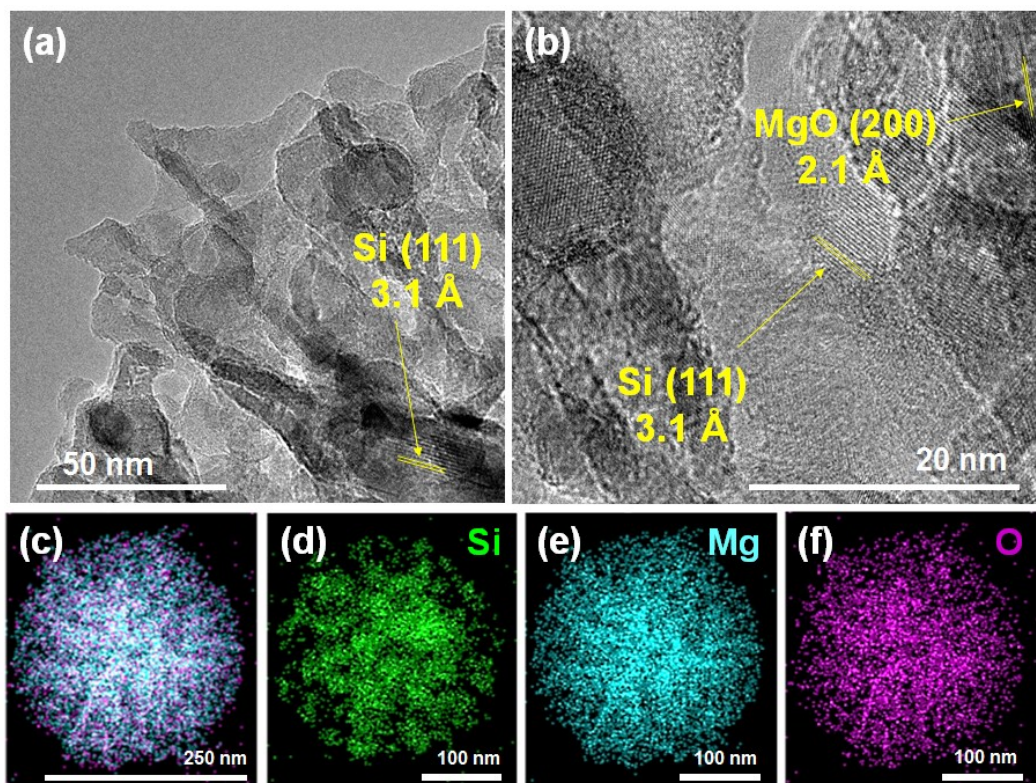


Fig. S1 Microstructure of cpSi+MgO composite particles. Cs-corrected HR-TEM image of the (a) edge and (b) core of cpSi+MgO. EDX elemental mapping images of the cpSi+MgO nanoparticle are shown for (c) all elements, (d) elemental Si, (e) elemental Mg, and (f) elemental O.

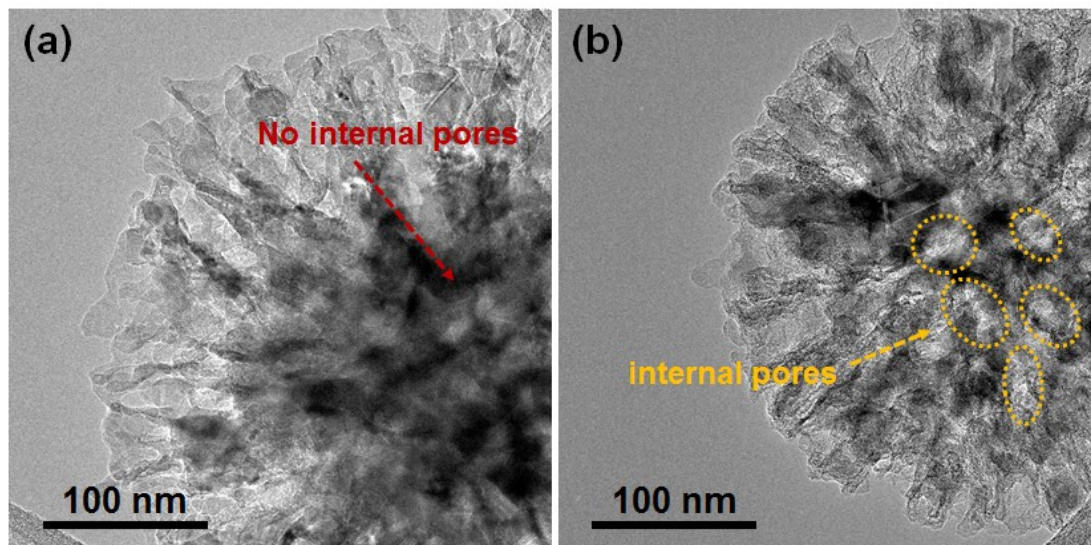


Fig. S2 Microstructure of nanoparticles presenting morphological differences of internal pore originated from MgO etching. C_s -corrected HR-TEM image of (a) before MgO etching (cpSi+MgO) and (b) after MgO etching and carbon coating (cpSi@C).

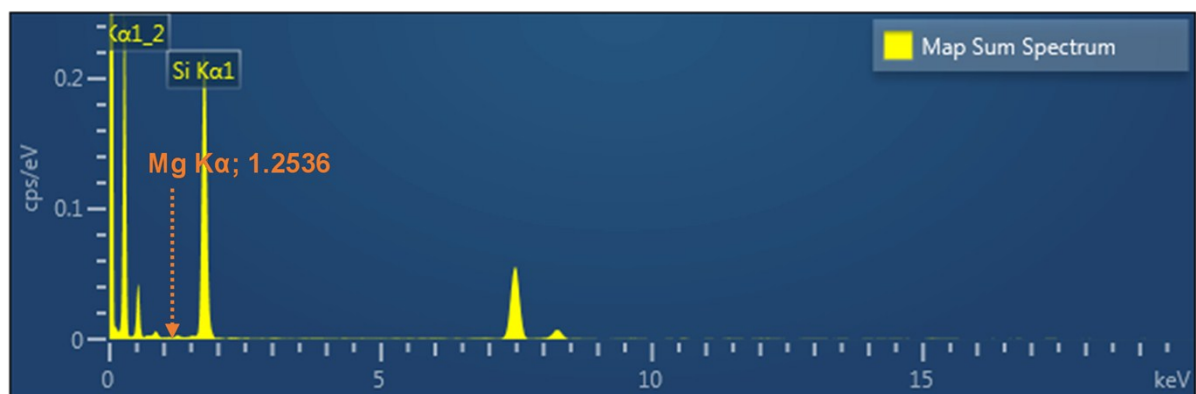


Fig. S3 EDX spectrum of cpSi@C; note that signal of Mg ($K\alpha=1.2536$) which can be from MgO residue does not exist.

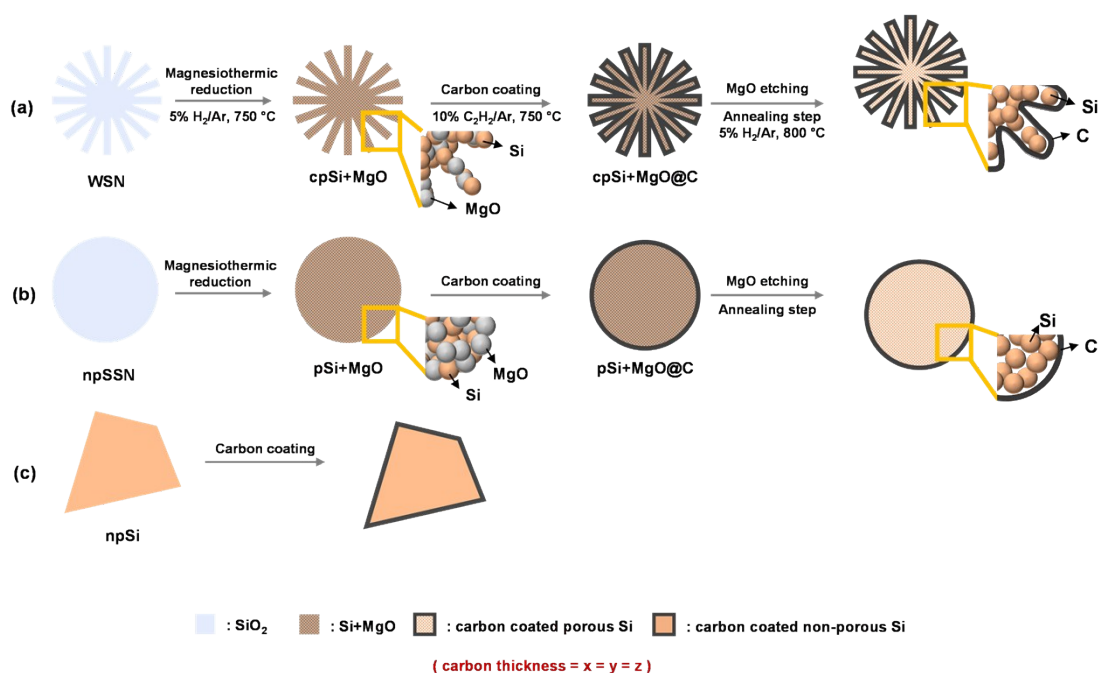


Fig. S4 Schematic illustration of the preparation of samples; (a) cpSi@C was synthesized from magnesiothermic reduction of WSNs, carbon coating, MgO etching, and annealing step; (b) pSi@C was prepared by magnesiothermic reduction of non-porous spherical SiO₂ nanoparticles (npSSN), carbon coating, MgO etching, and annealing step; (c) npSi@C was fabricated from commercial non-porous nanoparticles (npSi) with carbon coating. It should be noted that carbon was only coated on the contour surface region of the particles before MgO etching. Also, the MgO etching formed porosity inside the carbon layer for cpSi@C and pSi@C.

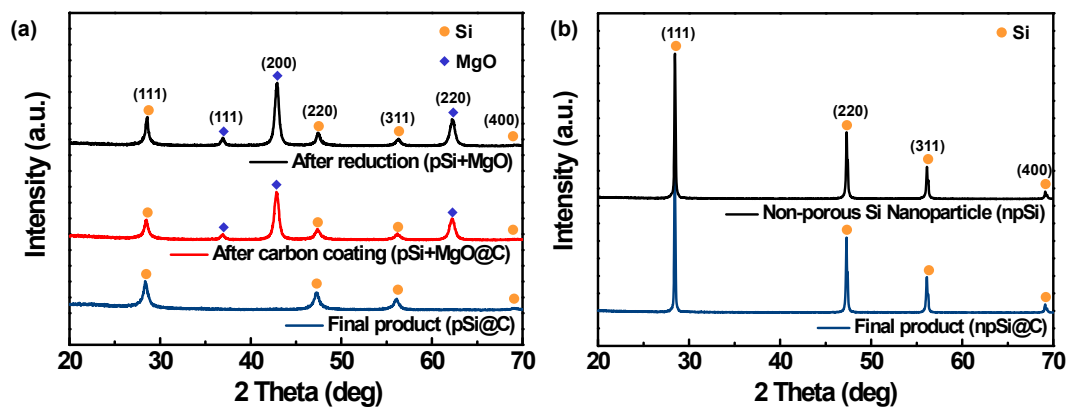


Fig. S5 XRD patterns of samples in the course of synthesizing (a) pSi@C and (b) npSi@C.

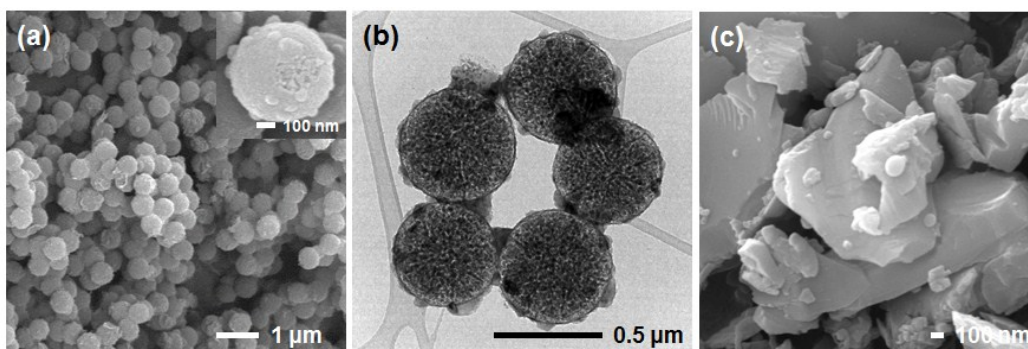


Fig. S6 FE-SEM and TEM images of two control samples. (a, b) pSi@C has spherical morphology formed of porous Si with a conformally coated carbon shell. (c) npSi@C has an irregular shape with a carbon layer because it was obtained from commercial non-porous Si, which had irregular particle morphology.

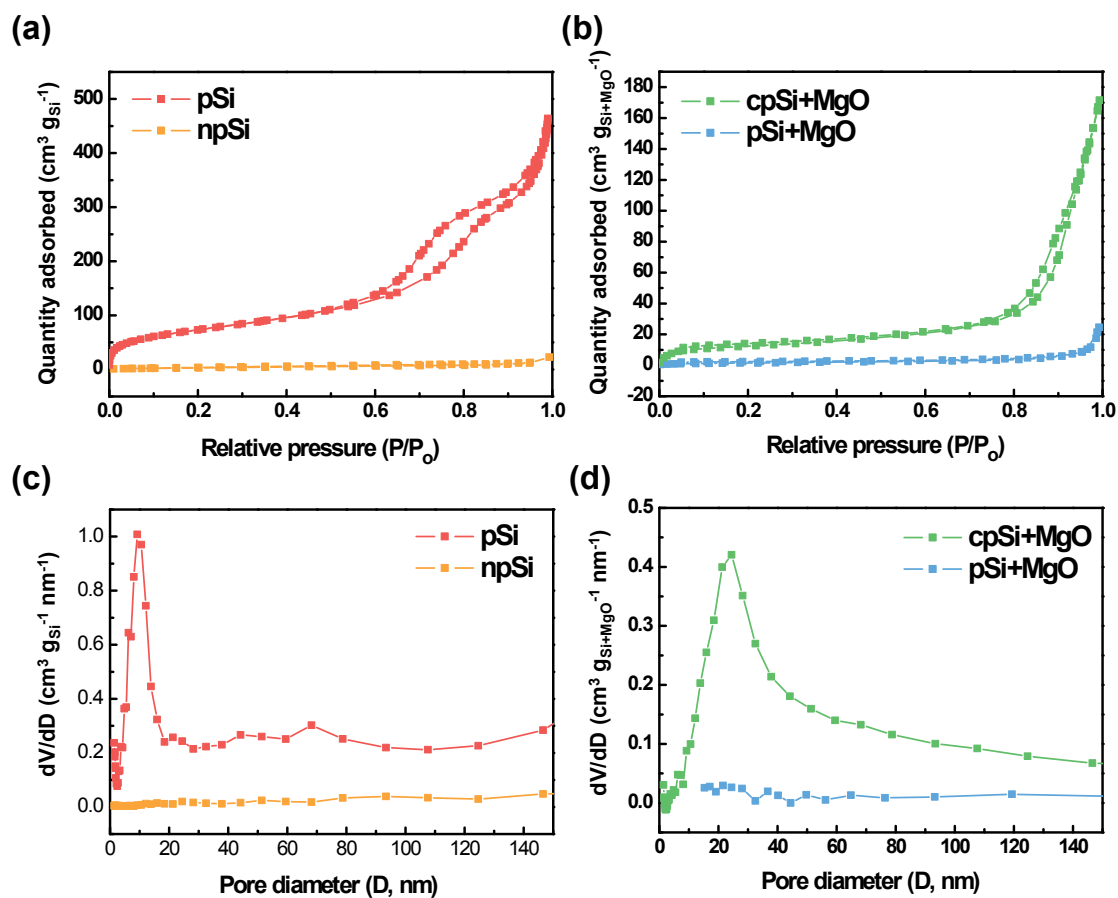


Fig. S7 N₂ sorption isotherms of (a) npSi, pSi, and (b) cpSi+MgO, pSi+MgO; BJH pore diameter distributions of (c) npSi, pSi, and (d) cpSi+MgO, pSi+MgO extracted from the adsorption branches of the isotherms. (pSi denotes the npSSN sample magnesiothermally reduced after MgO etching without carbon coating, V and D stand for pore volume and pore diameter, respectively.)

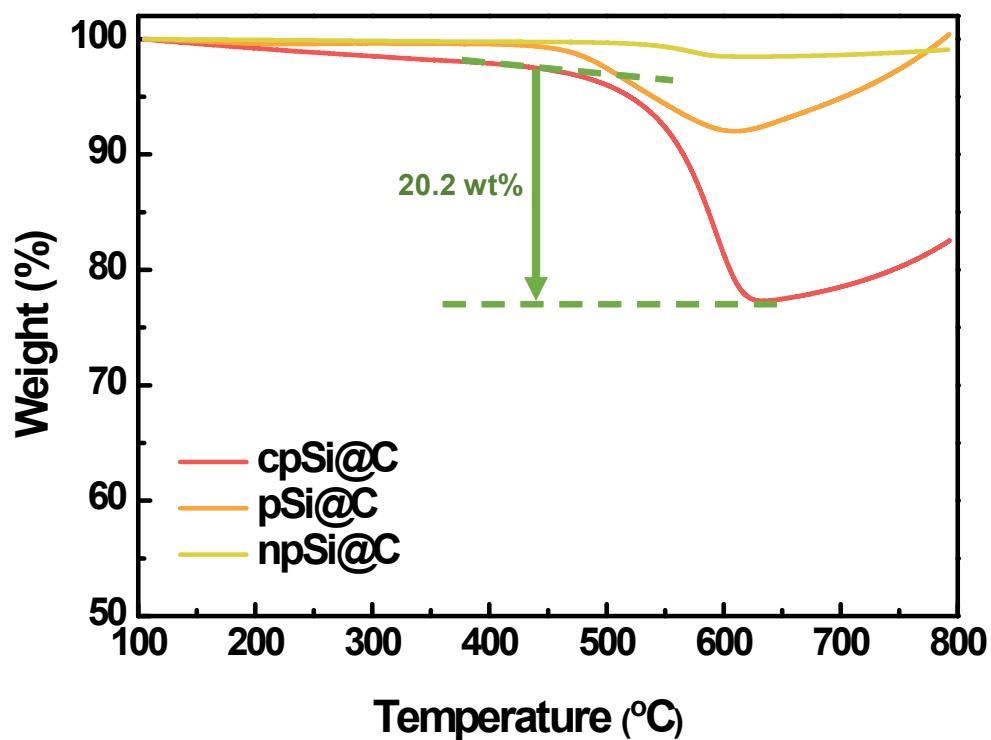


Fig. S8 TGA profile of cpSi@C, pSi@C, and npSi@C, demonstrating the pyrolytic decomposition of carbon around 600 °C under an atmosphere of artificial air (O₂ 21% and N₂ 79%). The gradual weight gains above 600 °C can be attributed to oxidation of Si. This indicates that the carbon contents are 20.2, 7.98, and 1.52 wt%, respectively.

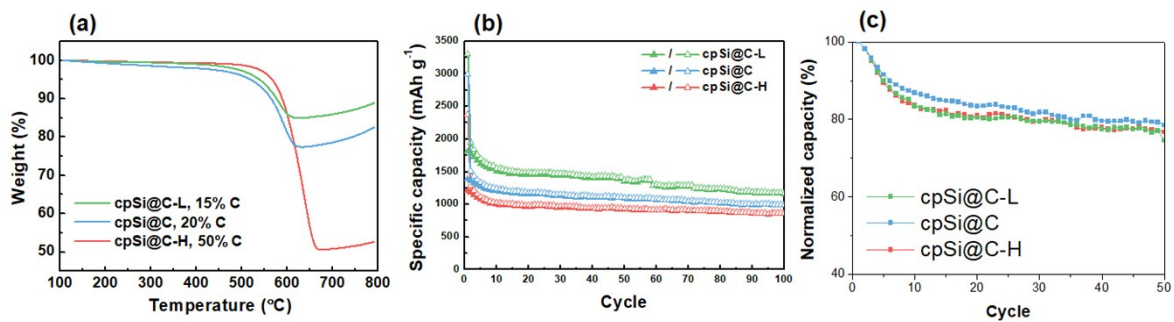


Fig. S9 (a) TGA plots, (b) cycling performances, and (c) normalized charging capacities of cpSi@C series samples with the varying carbon contents.

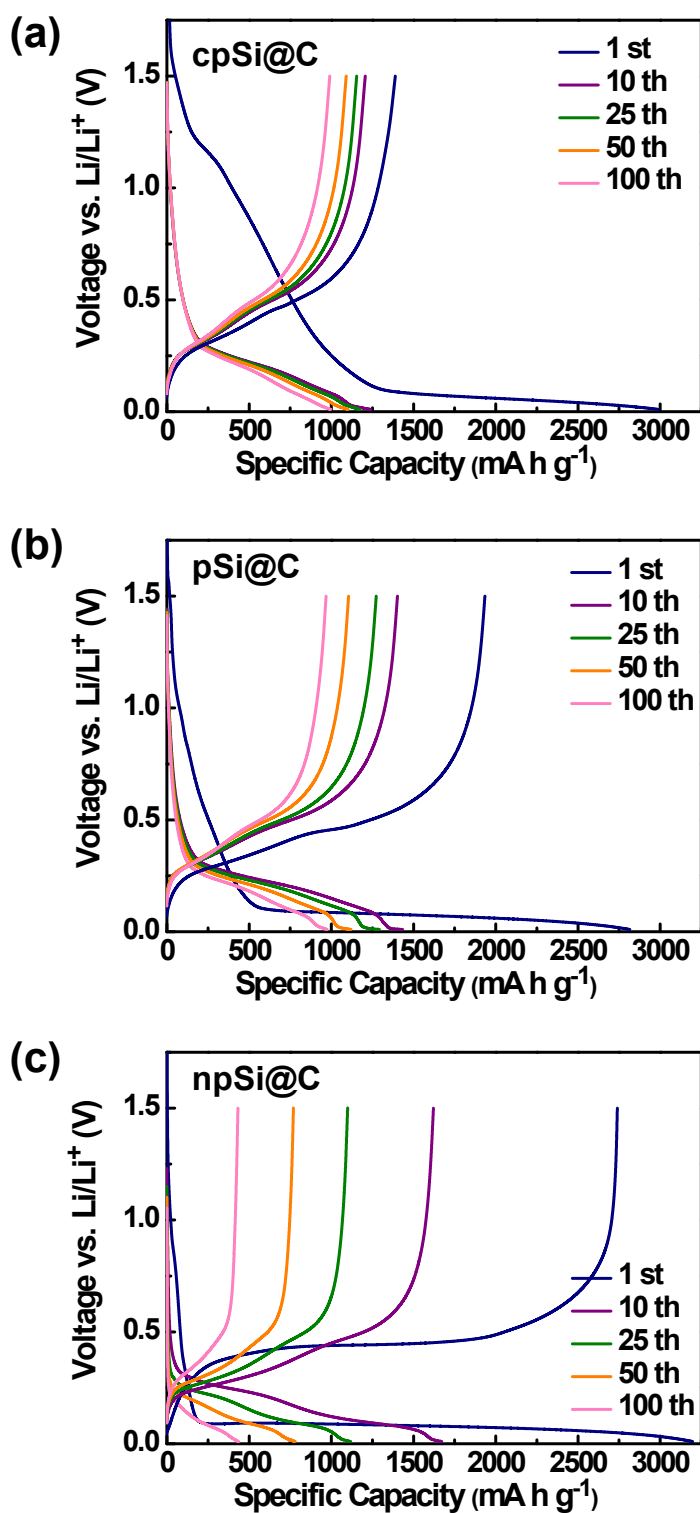


Fig. S10 Discharge-charge potential profiles of (a) cpSi@C, (b) pSi@C, and (c) npSi@C for the 1st, 10th, 25th, 50th, and 100th cycles at 0.5 A g⁻¹.

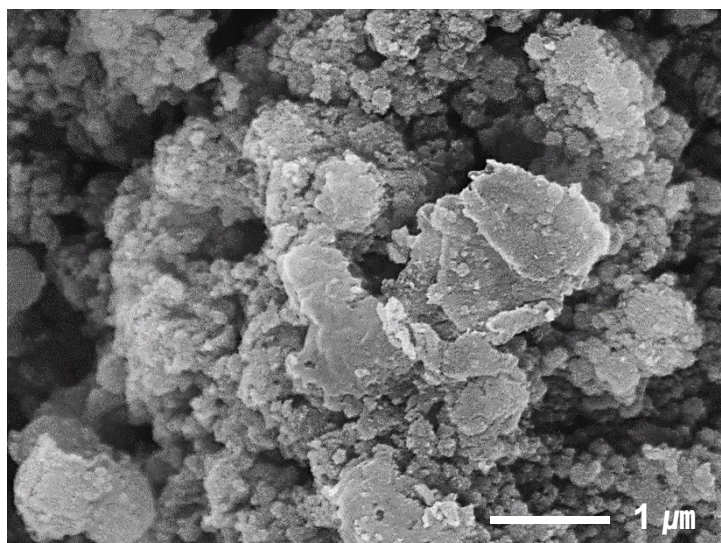


Fig. S11 SEM images of the pSi@C electrode after 50th cycles.

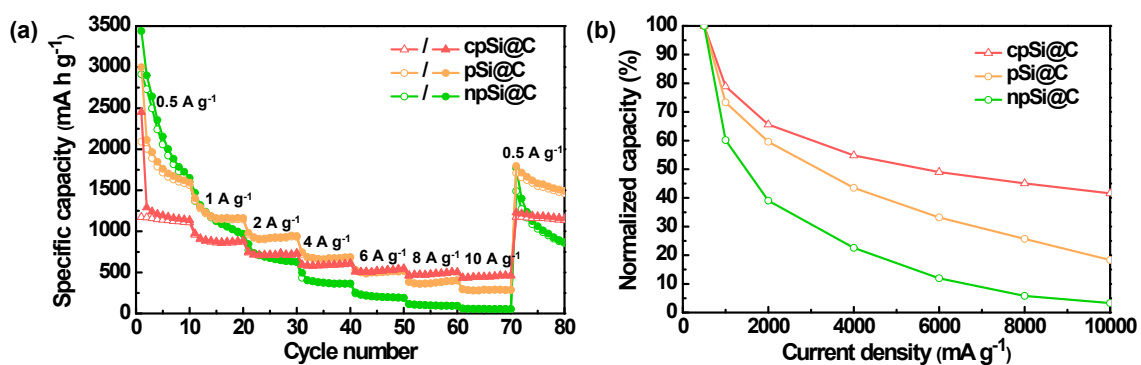


Fig. S12 (a) Rate capabilities for cpSi@C, pSi@C, and npSi@C; and (b) Normalized charge capacities for cpSi@C, pSi@C, and npSi@C at different current densities ranging from 0.5 to 10 A g^{-1} .

Table S1. Total pore volumes, ratios of total pore volume to Si volume, and carbon-coated contour surface areas for cpSi, pSi, and npSi

	Total pore volume [cm ³ g _{Si} ⁻¹]	Ratio of total pore volume to Si volume ^a [%]	Carbon coated contour surface area ^b [m ² g _{Si} ⁻¹]
Canyon-like porous structure (cpSi)	1.802 ^c	419	175.58
Porous structure (pSi)	0.716 (0.801) ^d	167 (187) ^d	63.04
Non-porous structure (npSi)	0.03	6.99	13.22

^{a)} See Calculation 1 in ESI[†] for details. ^{b)} Contour surface area on which carbon layer was coated (see Calculation 4 in ESI[†] for details). ^{c)} Theoretically calculated value; total pore volume of cpSi was calculated by adding the pore volume of the canyon-like structure and the pore volume from MgO etching (see Calculation 3 in ESI[†]), whereas the total pore volume of pSi and npSi were obtained from N₂ sorption experiments. ^{d)} Theoretically calculated value on the basis of only MgO etching contributing to the total pore volume. See Calculation 1 and 2.

Table S2. Performance comparison between cpSi@C and magnesiothermally prepared Si-C composites in literature.

Description of structure	maximum capacity ^a [mAh/g]	Retained capacity at specific cycles ^a [mAh/g]	Retention [%]	Rate [mA/g or C-rate]	Ref.
cpSi@C	1389	1090 (50 th) 990 (100 th) 822 (200 th)	78.5 71.6 59.1	500	This work
Porous Si from sand @reduced graphene oxide	~2625	~1400 (50 th)	53.3	200	S1
Porous Si from SiO ₂ nanoparticle+CNT	~2980 ^a	2200 (50 th)	73.8	0.05C	S2
Porous Si from sand @C	~2300	~1500 (100 th)	65.	1000	S3
Porous Si@C from reed plant	~2435	~1050 (200 th)	43.1	0.5C	S4

^a) Discharging capacity at second cycle was adopted, if charging capacity is not available.

S1 W.-S. Kim, Y. Hwa, J.-H. Shin, M. Yang, H.-J. Sohn and S.-H. Hong, *Nanoscale*, 2014, **6**, 4297-4302.

S2 W. Wang, Z. Favors, R. Ionescu, R. Ye, H. H. Bay, M. Ozkan and C. S. Ozkan, *Sci. Rep.*, 2015, **5**, 8781.

S3 J.-K. Yoo, J. Kim, M.-J. Choi, Y.-U. Park, J. Hong, K. M. Baek, K. Kang and Y. S. Jung, *Adv. Energy Mater.*, 2014, **4**, 1400622.

S4 J. Liu, P. Kopold, P. A. van Aken, J. Maier and Y. Yu, *Angew. Chem. Int. Ed.*, 2015, **54**, 9632-9636.